

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims, including those in the First Preliminary Amendment, in the application:

Listing of Claims:

Claim 1 (currently amended): ~~A High purity copper sulfate wherein the content comprising a high purity copper sulfate having a purity of 99.99wt% or higher and contents of Ag impurities is 1wtppm or of less than 0.01wtppm, and having a purity of 99.99wt% or higher metalloid element impurities of As, Sb, and Bi of less than 0.1wtppm, respectively, radioactive elements of U and Th of less than 0.001wtppm, respectively, and heavy metal elements of Fe, Cr, and Ni of less than 0.1wtppm, respectively.~~

Claims 2-6 (canceled).

Claim 7 (currently amended): ~~A manufacturing method of manufacturing high purity copper sulfate including comprising the steps of dissolving crude copper sulfate crystals or copper metal having a purity of 95 to 99.5 wt%, and subjecting this to active carbon treatment or and solvent extraction and active carbon treatment in order to realize recrystallization and to produce a high purity copper sulfate having a purity of 99.99wt% or higher and contents of Ag impurities of less than 0.01wtppm, metalloid element impurities of As, Sb, and Bi of less than 0.1wtppm, respectively, radioactive elements of U and Th of less than 0.001wtppm, respectively, and heavy metal elements of Fe, Cr, and Ni of less than 0.1wtppm, respectively.~~

Claim 8 (canceled).

Claim 9 (new): A copper sulfate according to claim 1, wherein undissolved residue of 1 μm or greater in water exists in an amount of 100 residues/L or less.

Claim 10 (new): A copper sulfate according claim 9, wherein said high purity copper sulfate has a purity of 99.999wt% or higher.

Claim 11(new): A copper sulfate according claim 1, wherein said high purity copper sulfate has a purity of 99.999wt% or higher.

Claim 12 (new): A method according to claim 7, wherein undissolved residue of 1 μm or greater in water exists in said high purity copper sulfate in an amount of 100 residues/L or less.

Claim 13 (new): A method according claim 12, wherein said high purity copper sulfate has a purity of 99.999wt% or higher.

Claim 14 (new): A method according claim 7, wherein said high purity copper sulfate has a purity of 99.999wt% or higher.